

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Muneo ISHIDA  
For : ACTION  
Docket : ADACHI P252US

The Commissioner for Patents  
U.S. Patent & Trademark Office  
P. O. Box 1450  
Alexandria, VA 22313-1450

**INFORMATION DISCLOSURE STATEMENT**

Dear Sir:

In connection with this matter, the Applicant hereby attaches one (1) United States Patent Office Form PTO-1449 and copies of the information listed in the enclosed PTO-1449 Form, unless otherwise indicated on such Form.

The concise explanation of the relevance of any foreign language prior art is indicated in paragraph [007] of the accompanying specification of the present application.

In the event that there are any fee deficiencies or additional fees are payable, please charge the same or credit any overpayment to our Deposit Account (Account No. 04-0213).

Respectfully submitted,



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(Rev.2-32)

PATENT AND TRADEMARK OFFICE  
INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT  
(Use several sheets if necessary)

Serial No.:  
Filing Date:  
Examiner:  
Group:  
Applicant: Muneo ISHIDA

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Sub- Class	Filing Date, if Appropriate
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FOREIGN PATENT DOCUMENTS

Examiner Initials	Document Number	Date	Country	Sub- Class	Class	Translation Yes No
	10-20858		Japan			X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

Examiner \_\_\_\_\_ Date Considered \_\_\_\_\_

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.